Inventor:

John F. Van Itallie et al.

Title:

Photolithographic Methods of Using a Single Reticle to Form Overlapping

Patterns

Assignee:

Micron Technology, Inc.

INFORMATION DISCLOSURE STATEMENT

PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449. No admission is made regarding whether all the submitted references are prior art.

The listed references were cited by, or submitted to, the Office in the parent, co-pending application of the above-identified application, except for U. S. Patent Application Serial No. US2003/0152844A1. The above-identified application is a continuation application of co-pending application Serial No. 09/943,186, filed August 29, 2001. Such prior disclosure is sufficient for the above-identified application as far as copies of the references are concerned, except for U. S. Patent Application Serial No. US2003/0152844A1. 37 C.F.R. § 1.98(d) and MPEP § 609(2).

Citation of these references is respectfully requested.

Respectfully submitted,

Dated:

By:

David G. Latwesen, Ph.D.

Reg. No. 38,533

Form PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY, DOCKET NO. Mi22-2458

APPLICANT John F. Van Itallie

SERIAL NO. PRIORITY
OD/D41 104

LIST OF ART CITED BY APPLICANT

(Use several sheets if necessary)

						August 29, 2001		Unkn	OWN_		
			_		U.S. PATENT DOCUMENTS				- ··		
*Examiner Initial		Docur Numb	ment er	Date	Name		Class	Subclass	Filing If Appr	Date ropriate	
	AA	6,248,	508 B1	06-2001	Murooka et al.					·	
	AB	US200	03/0152844A1	08-2003	Dulman			,	Feb. 5, 2002		
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OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)											
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